

Enhanced resonant backscattering of light from quantum-well excitons

Vincenzo Savona, Erich Runge, and Roland Zimmermann

Institut für Physik der Humboldt-Universität zu Berlin, Hausvogteiplatz 5-7, D-10117 Berlin, Germany

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The angle-dependent resonant Rayleigh scattering of light from excitons in a disordered quantum well is studied theoretically. An enhancement of the scattered intensity peaked on the backscattering direction is predicted, for values of the parameters corresponding to realistic GaAs/AlGaAs heterostructures. It is shown that this effect can be isolated by measuring the differential enhancement between two different scattering directions. An analysis in terms of perturbation theory provides a simple analytical approximation of the measurable quantity.

In recent years, the influence of structural disorder on the optical properties of excitons in semiconductor heterostructures has become the object of numerous experimental and theoretical investigations. In addition to improving our understanding of the physics of excitons, these studies are also part of a much broader perspective, aiming at the systematic study of the general properties of disordered systems through the investigation of the optical response of semiconductors. Of particular interest is the resonant Rayleigh scattering (RRS) mechanism,¹⁻⁹ namely, the resonant light scattering into all directions due to the localization of the exciton center of mass wave functions. RRS measurements using interferometric^{3,4} or speckle-resolved techniques⁷ proved to be a powerful tool for the study of dephasing processes in semiconductors. In addition, time-resolved RRS measurements⁹ and a microscopic RRS model⁸ have given access to the statistics of energy-level distances characterizing the exciton center-of-mass motion.

A general property of disordered systems consists in the enhanced backscattering (EBS) of a wave propagating through the disordered medium. The origin of this phenomenon lies in the time-reversal invariance of the system, which holds generally in absence of a magnetic field. The same mechanism is responsible for the weak localization of a quantum-mechanical particle in a disordered potential. The EBS of light has been observed in several light-scattering experiments in diffuse media,¹⁰ where the angular width of the EBS peak is related to the mean free path characterizing the multiple scattering process. In the case of electron transport in metals,¹¹ the EBS is responsible for the scaling behavior of the low-temperature conductivity and, in three-dimensional systems, of the metal-insulator transition. In semiconductors, the basic physics governing the EBS has been taken into account by Hanamura¹² in conjunction with Coulomb interaction to describe the generation of conjugated waves in four-wave mixing measurements. However, in this work the single-scattering contribution to EBS which we show to be dominant, was neglected. Apart from this single application, the relevance of EBS in the framework of RRS measurements on quantum wells has never been addressed, despite the generality of the phenomenon.

In this work we evaluate the resonant EBS of light at the exciton transition in a quantum well with in-plane disorder. We demonstrate that, in a realistic experimental situation, the

EBS can be evidenced in a differential enhancement measurement, where the scattered intensities along and across the plane of incidence are compared. By means of a perturbation theory, we provide an analytical expression of EBS which satisfactorily accounts for the numerical results.

In what follows we adopt the theory of resonant Rayleigh scattering of excitons in quantum wells that we have recently developed in Ref. 8. It is assumed that the disorder affects the exciton center-of-mass motion giving rise to localized exciton eigenstates. The microscopic exciton polarization $P(\mathbf{R}, t)$ is proportional to the exciton center-of-mass wave function. An incoming electromagnetic wave drives the exciton polarization which propagates according to the Schrödinger equation

$$-i\hbar\partial_t P(\mathbf{R}, t) = \left(-\frac{\hbar^2}{2M}\Delta_{\mathbf{R}} + V_{\mathbf{R}} + \hbar\omega_x \right) P(\mathbf{R}, t) + i\gamma P(\mathbf{R}, t) + \mu E_{in}(\mathbf{R}, t). \quad (1)$$

Here, $\hbar\omega_x$ is the average exciton energy which we set to zero for simplicity, and γ is the homogeneous damping term, accounting for radiative recombination and dephasing processes. The potential $V_{\mathbf{R}}$ describes the effect of disorder on the exciton center-of-mass motion. Within our model, $V_{\mathbf{R}}$ is a randomly distributed spatially correlated potential characterized by

$$\langle V_{\mathbf{R}} V_{\mathbf{R}'} \rangle = \sigma^2 f_{\mathbf{R}-\mathbf{R}'}, \quad (2)$$

where σ is the average amplitude of fluctuations and $f_{\mathbf{R}}$ is a correlation function with $f(0) = 1$. Here the angular brackets denote an average over the statistical ensemble. For the present calculation, we take a Gauss correlation $f_{\mathbf{R}} = \exp(-R^2/2\xi^2)$, where ξ is the disorder correlation length.

The resonantly scattered field is, in the far-field limit, proportional to the Fourier transform of $P(\mathbf{R}, t)$. We are interested in the frequency- and angle-resolved scattered intensity defined as $I_{\mathbf{k}_{in}}(\mathbf{k}_{out}, \omega) \propto |P_{\mathbf{k}_{in}}(\mathbf{k}_{out}, \omega)|^2$, where

$$P_{\mathbf{k}_{in}}(\mathbf{k}_{out}, \omega) = \int d\mathbf{R} \int dt P_{\mathbf{k}_{in}}(\mathbf{R}, t) e^{-i(\omega t - \mathbf{k}_{out} \cdot \mathbf{R})}, \quad (3)$$

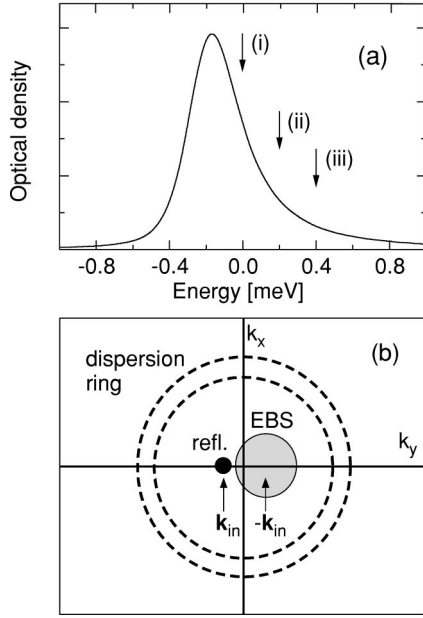


FIG. 1. (a) Computed exciton optical density. The labeled arrows refer to the three energy values considered in Fig. 2. (b) Sketch of the different contributions to the RRS intensity in the \mathbf{k}_{out} plane for fixed ω . The dispersion ring (dashed) represents the exciton resonance, the black spot positioned at \mathbf{k}_{in} corresponds to the reflected signal, while the shaded circle centered at $\mathbf{k}_{out} = -\mathbf{k}_{in}$ represents the broad EBS feature.

and $P_{\mathbf{k}_{in}}(\mathbf{R}, t)$ is the numerical solution of Eq. (1) for an incoming short-pulse field $E_{in}(\mathbf{R}, t) = \delta(t)\exp(-i\mathbf{k}_{in} \cdot \mathbf{R})$. The intensity is then averaged over several realizations of the disordered potential.

We point out that, with the exception of speckle-resolved measurements,^{3,4,7} in a typical experimental setup the measured intensity is always averaged over a solid angle larger than the angular speckle size, the latter being inversely proportional to the excitation focus. Such speckle average is equivalent to a configuration average, as shown in Ref. 8. The angle-dependent features that we investigate in the present paper, however, take place over a scale much larger than the typical averaging angle. They are thus correctly described within our configuration-average approach.

The numerical results presented below are computed for $\mathbf{k}_{in} = (-0.005, 0) \text{ nm}^{-1}$, defined on the (k_x, k_y) plane. The other parameters are set to $\sigma = 0.5 \text{ meV}$, $\xi = 10 \text{ nm}$, and $\gamma = 35 \mu\text{eV}$. Figure 1(a) displays the optical density of the exciton, defined as the imaginary part of $P_{\mathbf{k}_{in}}(\mathbf{k}_{in}, \omega)$, as a function of $\hbar\omega$. It corresponds to the spectral function of the exciton center-of-mass motion. In Fig. 2(a) we plot the scattered intensity $I_{\mathbf{k}_{in}}(\mathbf{k}_{out}, \omega)$ as a function of \mathbf{k}_{out} for three different values of ω lying on the high-energy tail of the exciton spectral function, as indicated by the arrows in Fig. 1(a). For the thick lines in Fig. 2(a), \mathbf{k}_{out} is varied along the \mathbf{k}_x direction while the thin lines represent the intensity for \mathbf{k}_{out} varying along the \mathbf{k}_y direction. The strong reflected signal shows up in the three thick curves as a sharp peak at $\mathbf{k}_{out} = \mathbf{k}_{in}$. The two peaks appearing in each plot at symmetrical positions with respect to the origin correspond to the exciton resonance, translated into \mathbf{k}_{out} via the exciton dispersion $\hbar(\omega - \omega_x) = \hbar^2 k_{out}^2 / (2M)$. The enhanced backscattering

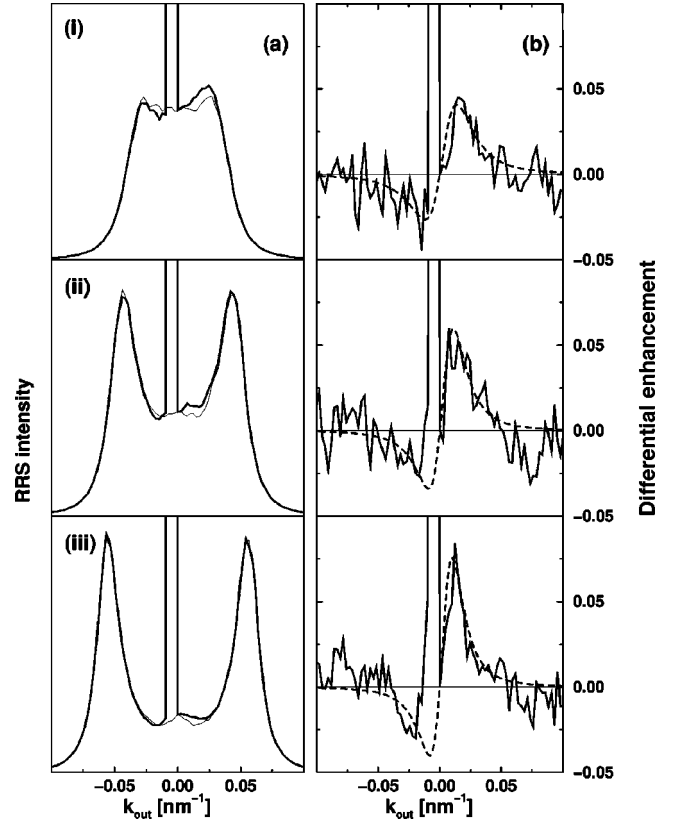


FIG. 2. (a) RRS intensity as a function of \mathbf{k}_{out} for $\mathbf{k}_{in} = -0.005 \text{ nm}^{-1}$ and $\hbar\omega = 0$ (i), $\hbar\omega = 0.2 \text{ meV}$ (ii), and $\hbar\omega = 0.4 \text{ meV}$ (iii), as indicated by the corresponding arrows in Fig. 1. \mathbf{k}_{out} varies along the \mathbf{k}_x direction (thick line) and along the \mathbf{k}_y direction (thin line). (b) Corresponding plots of the differential enhancement Eq. (4) (full line). The dashed curves are fits obtained using the analytical result Eq. (7).

manifests itself as a broad, small feature, centered on $\mathbf{k}_{out} = -\mathbf{k}_{in}$. By construction, the thin curves are totally symmetric, displaying the exciton-dispersion peaks, but neither the reflected nor the backscattered feature, as expected. All these features are better understood looking at a sketch of the scattered intensity on the \mathbf{k}_{out} plane, as displayed in Fig. 1(b), where the reflected and backscattered peaks appear as a sharp and a broad feature centered on \mathbf{k}_{in} and $-\mathbf{k}_{in}$, respectively, whereas the ring-shaped feature corresponds to the exciton dispersion. Since the backscattering enhancement appears as a rather faint feature in Fig. 2(a), we propose as a possible measurable quantity the differential enhancement, defined as

$$I_D(k, \omega) = \frac{I_{\mathbf{k}_{in}}((k, 0), \omega) - I_{\mathbf{k}_{in}}((0, k), \omega)}{I_{\mathbf{k}_{in}}((k, 0), \omega) + I_{\mathbf{k}_{in}}((0, k), \omega)}, \quad (4)$$

namely the fractional enhancement of the thick with respect to the thin lines in the plots of Fig. 2(a). This quantity is plotted in Fig. 2(b). Apart from the noise—originating from insufficient configuration averaging and amplified in this differential quantity—the enhanced backscattering feature is now well resolved as an overall variation of about ten percent. The EBS feature in both Figs. 2(a) and 2(b) is partially hidden by the large reflected peak which is rather broad. The width of the reflected peak is, however, not realistic in our

on these considerations and having adopted a finite value of γ in the present calculations, we suggest the following simple expression for the T matrix:

$$T(\mathbf{k}_{in}, \mathbf{k}_{out}, \omega) = \frac{1 + \alpha}{\Gamma^2} + \frac{\alpha}{(\mathbf{k}_{in} + \mathbf{k}_{out})^2 + \Gamma^2}. \quad (7)$$

The functional form of this expression derives from the analytical result of the perturbation approach applied to the one-dimensional case with spatially uncorrelated disordered potential.¹⁵ In particular, the first and second terms on the right side of Eq. (7) correspond to the ladder and maximally crossed series, respectively, and the 1 appears since L contains a first order diagram which has no counterpart in X . This first order diagram plays here a role analogous to the single-scattering paths mentioned above in the case of light scattering in diffuse media. We notice that the ladder contribution is \mathbf{k} independent, while the maximally crossed term is peaked at the EBS wave vector. In 1D perturbation theory for the spatially uncorrelated case, the quantities α and Γ are well defined functions of ω and the homogeneous exciton broadening γ . In the present two-dimensional spatially correlated situation, however, Eq. (7) should be considered only as a phenomenological expression, with α and Γ being two fit parameters. The fit of Eq. (7) to the numerically computed

I_D is plotted in Fig. 2(b) as a dashed line. The δ -like reflected contribution to the scattered intensity has intentionally been omitted in the analytical approximation. It would correspond to the zeroth order diagram of two disconnected lines, $G^+(\mathbf{k}_{in}, \omega)G^-(\mathbf{k}_{in}, \omega)\delta_{\mathbf{k}_{in}, \mathbf{k}_{out}}$, not included in the analysis of Fig. 3(a). We notice that the four propagators, by which the T matrix has to be multiplied to obtain the scattered intensity according to Fig. 3(a), are mainly responsible for the dispersion ring in the scattered intensity. They depend on the absolute value of \mathbf{k} only and are thus canceled in the ratio Eq. (4). The success in reproducing our numerical results suggests that Eq. (7) could be used to model the proposed measurement.

In conclusion, we have presented numerical results of frequency- and angle-resolved RRS, based on an existing model of the microscopic exciton polarization in a quantum well with in-plane disorder. We demonstrate a sizeable enhancement of the backscattered light intensity for realistic values of the exciton and disorder parameters. An experimental verification of our prediction would provide the first evidence of disorder-induced EBS in semiconductor heterostructures. We propose a differential measurement in which the EBS shows up clearly, and derive a simple analytical expression which could be used to fit the outcome of forthcoming experiments.

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